

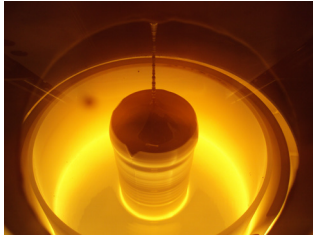
Silicon Services



- Downsizing
- Laser marking
- Crystal reclaim
- Silicon Ingot
- Surface preparation
- Polishing
- Slicing
- Dicing
- Edge rounding



CZ SPECIFIC INGOT



- Orientation (100) or (111)
- Dopant: P-Boron or N-Phosphorus
- From conductive materials to 1 mOhm.cm
- Undoped: no added dopant

MACHINING - DICING - SLICING



From ingots, blocks or wafers, we offer a variety of processes to shape your material:

- Crystal or flat orientation
- Shaping wafers into (pseudo) squares
- Slicing with diamond inner diameter saw (ID)
- Dicing (minimum size: 1.5 mm x 1.5 mm)

POLISHING - RECLAIM

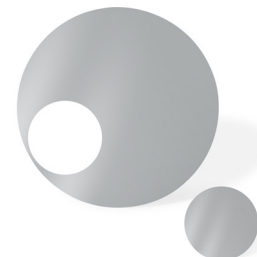


- From ingots, blocks or wafers, we offer a variety of processes. We propose a large variety of surface finishing for your materials:
- Lapping, back-grinding, single side or double side polishing
 - High level finishing for special application (ex: "Epi-ready" finishing for electrochemical growth)
 - Special treatment for bonding

SIL'TRONIX ST can reclaim your wafers. Depending on layer deposition, marks or defects on surface, we adjust our reclaim steps to offer you recycled wafers for a fraction of the cost of prime wafers.

DOWNSIZING - EDGE GRINDING

- Downsizing wafers or SOI wafers by laser cutting (ie: 6" -> 3x2")
- Round, flat, edge grinding
- Specific edge profile (ie, angle at 45°...)



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